

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L6	1	"6652654".pn.	US-PGPUB; USPAT; USOCR	OR	OFF	2007/10/16 12:49
L9	1	6 and (substrate and supercritical)	US-PGPUB; USPAT; USOCR	OR	OFF	2007/10/16 12:55
L10	82	134/43.ccls.	US-PGPUB; USPAT; USOCR	OR	OFF	2007/10/16 12:55
S1	20	"521906"	US-PGPUB; USPAT; USOCR	OR	OFF	2007/10/16 07:16
S2	1	"4944923".pn.	US-PGPUB; USPAT; USOCR	OR	OFF	2007/10/16 07:16
S3	24	("3483089" "3933440" "4228134" "4303615" "4335074" "4406861" "4750610").PN. OR ("4944923").URPN.	US-PGPUB; USPAT; USOCR	OR	OFF	2007/10/16 07:17
S4	22	("3179122" "3265296" "3459369" "4079854" "4151253" "4168012" "4342419" "4672996" "4689306" "4690670" "4752445" "4882128" "4944425" "4944923" "4993602" "5270010").PN. OR ("5368820"). URPN.	US-PGPUB; USPAT; USOCR	OR	OFF	2007/10/16 07:30
S5	45	((substrate or semiconductor or wafer) with (batch)) and (high same pressure) and (cylindrical same pressure same (vessel or drum or tank or receptacle))	US-PGPUB; USPAT; USOCR	OR	OFF	2007/10/16 07:49
S6	18	("4471949" "4522660" "5137755" "5167716" "5307568" "5458688" "5518771" "5527561" "5556275" "5711811" "5897311" "5932289").PN. OR ("6491518").URPN.	US-PGPUB; USPAT; USOCR	OR	OFF	2007/10/16 07:36
S7	10	((substrate or semiconductor or wafer) with (batch)) and (bound\$3 near3 frame)	US-PGPUB; USPAT; USOCR	OR	OFF	2007/10/16 09:31
S8	2400	((substrate or semiconductor or wafer) with (batch)) and frame	US-PGPUB; USPAT; USOCR	OR	OFF	2007/10/16 07:50
S9	97	((substrate or semiconductor or wafer) with (batch)) with frame	US-PGPUB; USPAT; USOCR	OR	OFF	2007/10/16 07:53

EAST Search History

S10	24	S5 and (critical or supercritical)	US-PGPUB; USPAT; USOCR	OR	OFF	2007/10/16 07:54
S11	7	("2004/0096586").URPN.	USPAT	OR	OFF	2007/10/16 07:57
S12	14	("3548062" "3752456" "4022446" "4217087" "4238667" "4279581").PN. OR ("4471949"). URPN.	US-PGPUB; USPAT; USOCR	OR	OFF	2007/10/16 08:34
S13	303	substrate same supercritical same fluid same chamber	US-PGPUB; USPAT; USOCR	OR	OFF	2007/10/16 09:06
S14	1	"6491882".pn.	US-PGPUB; USPAT; USOCR	OR	OFF	2007/10/16 08:44
S15	6	("3775043" "4152111" "5288462" "5631029").PN. OR ("6491882").URPN.	US-PGPUB; USPAT; USOCR	OR	OFF	2007/10/16 08:52
S16	0	"96203187.8"	EPO; DERWENT	OR	OFF	2007/10/16 08:52
S17	0	"962031878"	EPO; DERWENT	OR	OFF	2007/10/16 08:52
S18	0	"96203187"	EPO; DERWENT	OR	OFF	2007/10/16 08:52
S19	0	"96203187"	EPO	OR	OFF	2007/10/16 08:52
S20	7	substrate same supercritical same fluid same chamber same batch	US-PGPUB; USPAT; USOCR	OR	OFF	2007/10/16 09:06
S21	448	(substrate or semiconductor or wafer) and supercritical and ((carbon near3 dioxide) and (nitrous near3 oxide) and (ethane or propane))	US-PGPUB; USPAT; USOCR	OR	OFF	2007/10/16 09:33
S22	158	S21 and batch	US-PGPUB; USPAT; USOCR	OR	OFF	2007/10/16 09:33